

Silicon Sensors for HL-LHC Tracking Detectors

N25: Radiation Damage Effects
31. October 2012

Susanne Kuehn
University of Freiburg, Germany
On behalf of the RD50 Collaboration

RD50 - Radiation hard semiconductor devices for very high luminosity colliders

- Introduction
- Research Fields of RD50
 - Material and Defect Characterization
 - Detector Characterization and Simulation
 - Full Detector Systems
 - New Structures
- Achievements and Findings for LHC Experiments

Only a selection on interesting topics, the full variety of RD50 can be found on:
<http://rd50.web.cern.ch/rd50/>

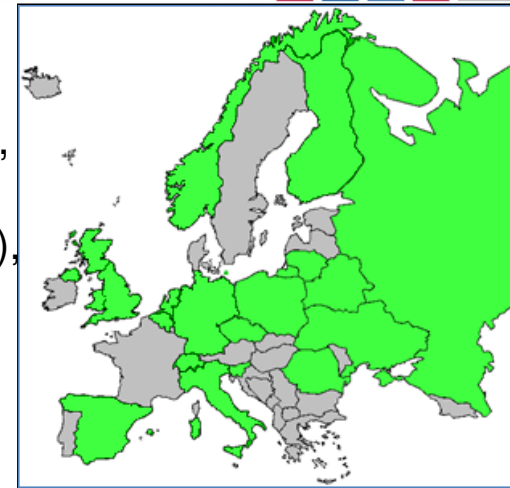
The RD 50 Collaboration

Albert-Ludwigs-Universität Freiburg



38 European and Asian institutes

Belarus (Minsk), **Belgium** (Louvain), **Czech Republic** (Prague (3x)), **Finland** (Helsinki, Lappeenranta), **Germany** (Dortmund, Erfurt, Freiburg, Hamburg, Karlsruhe, Munich), **Italy** (Bari, Florence, Padova, Perugia, Pisa, Trento), **Lithuania** (Vilnius), **Netherlands** (NIKHEF), **Norway** (Oslo)), **Poland** (Krakow, Warsaw(2x)), **Romania** (Bucharest (2x)), **Russia** (Moscow, St.Petersburg), **Slovenia** (Ljubljana), **Spain** (Barcelona(2x), Santander, Valencia), **Switzerland** (CERN, PSI), **Ukraine** (Kiev), **United Kingdom** (Glasgow, Liverpool)

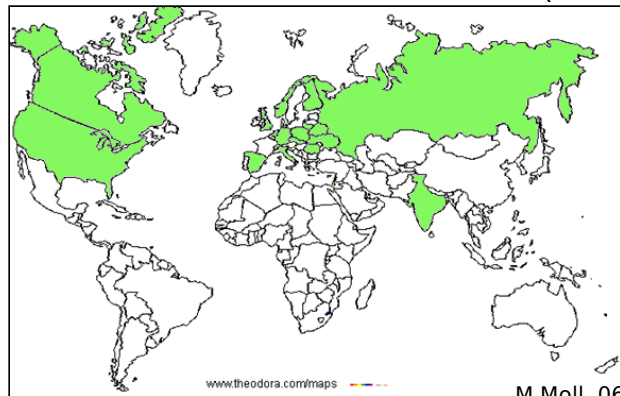


8 North-American institutes

Canada (Montreal), **USA** (BNL, Fermilab, New Mexico, Purdue, Santa Cruz, Syracuse)

1 Middle East institute Israel (Tel Aviv)

1 Asian institute India (Delhi) since 2011/12



www.theodora.com/maps M.MoIl_06/2012

→ **48 institutes and 261 members**

14th Workshop
in Freiburg, 2009



10th Anniversary

First workshop and
approval of collaboration in 2002

More details on: <http://rd50.web.cern.ch/rd50/>

Co-Spokespersons

Gianluigi Casse and **Michael Moll**
(Liverpool University) (CERN PH-DT)

Defect / Material Characterization

Mara Bruzzi
(INFN & Uni Florence)

- Characterization of microscopic properties of standard-, defect engineered and new materials pre- and post-irradiation
- **WODEAN: Workshop on Defect Analysis in Silicon Detectors** (G.Lindstroem & M.Bruzzi)

Detector Characterization

Eckhart Fretwurst
(Hamburg University)

- Characterization of test structures (IV, CV, CCE, TCT)
- Development and testing of defect engineered silicon devices
- EPI, MCZ and other materials
- NIEL
- Device modeling
- Operational conditions
- Common irradiations
- New Materials (E.Verbitskaya)
- Wafer procurement (M.Moll)
- **Simulations** (V.Eremin)

New Structures

Richard Bates (Glasgow Uni)
Giulio Pellegrini (CNM Barcelona)

- 3D detectors
- Thin detectors
- Cost effective solutions
- Other new structures
- 3D (R.Bates)
- Semi 3D (Z.Li)
- Thinned detectors
- Slim Edges (H.Sadrozinski)

Full Detector Systems

Gregor Kramberger
(Ljubljana University)

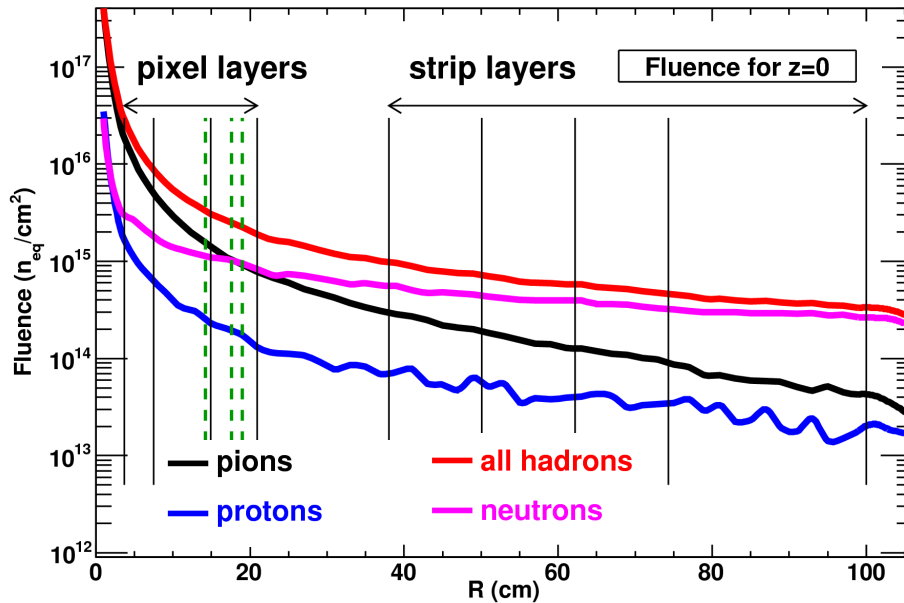
- LHC-like tests
- Test beams
- Links to HEP
- Links electronics R&D
- Comparison:
 - pad-mini-full detectors
 - different producers
- Pixel Europe (T.Rohe)
- Pixel US (D.Bortoletto)
- Test beams (G.Casse)

*Collaboration Board Chair & Deputy: E.Fretwurst (Hamburg) & J.Vaitkus (Vilnius), Conference committee: U.Parzefall (Freiburg)
CERN contact: M.Moll (PH-DT), Secretary: V.Wedlake (PH-DT), Budget holder & GLIMOS: M.Glaser (PH-DT)*

Challenge: Radiation Damage at the LHC

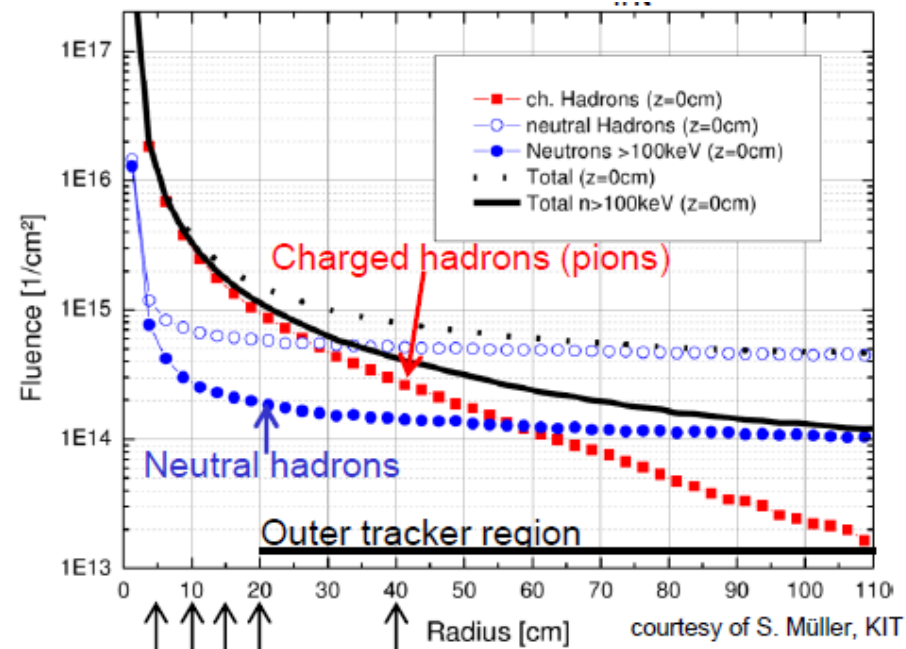
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Planned upgrade of the LHC in ~2022: 3000 fb⁻¹ expected integrated luminosity
 Expected particle fluences for
 the ATLAS Inner tracker:



ATLAS Radiation Taskforce
http://atlas.web.cern.ch/Atlas/GROUPS/PHYSICS/RADIATION/RadiationTF_document.html

the CMS tracker:



courtesy of S. Müller, KIT
 J. Erfle, 20th RD50 Workshop, 2012

→ Pixel damage due to neutrons and pions, strips mainly due to neutrons

→ Investigation and understanding of radiation damage of sensors needed

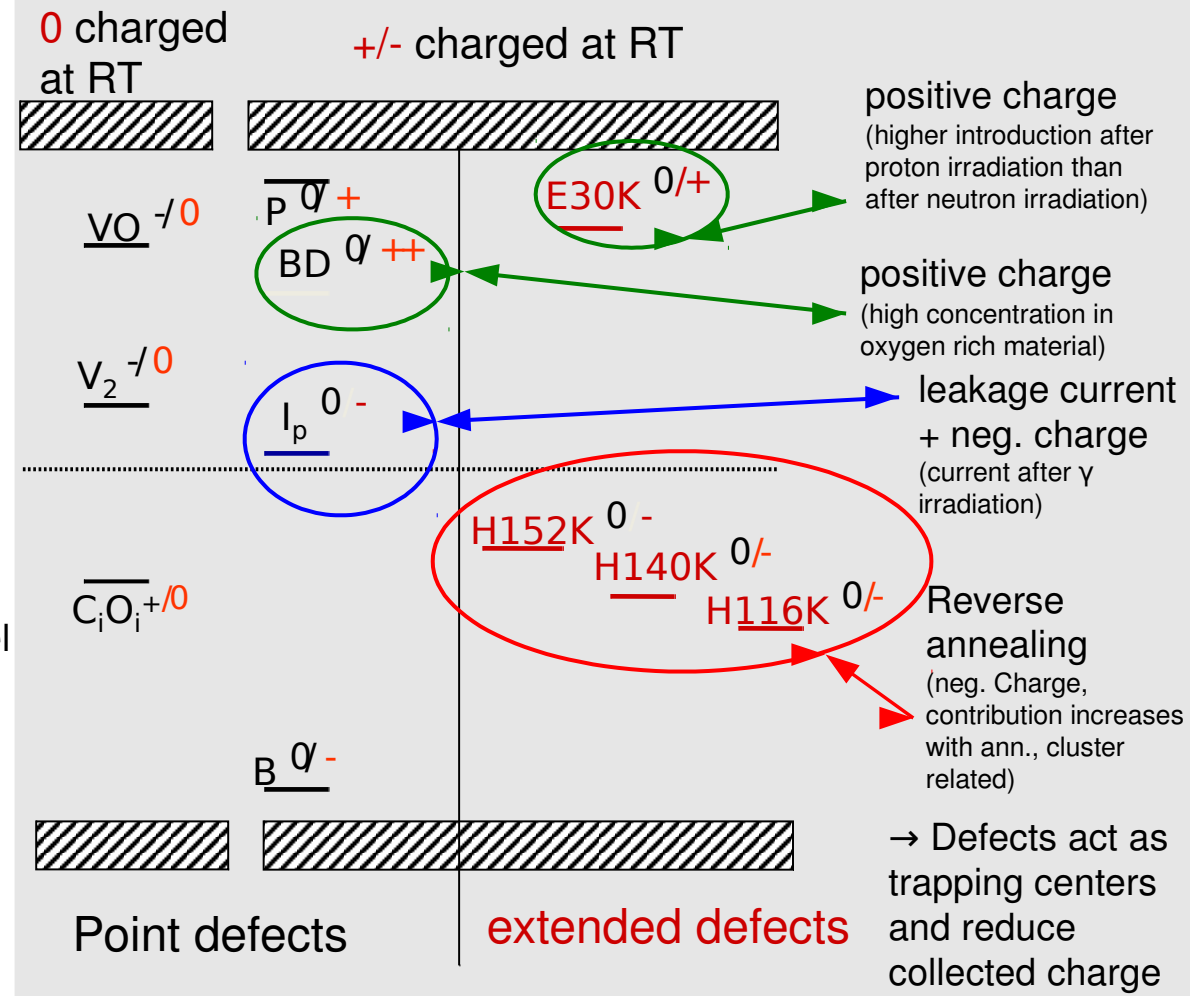
Defect and Material Characterization

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- WODEAN (Workshop on Defect Analysis in Silicon Detectors) since 2005 including 10 RD 50 institutes and lead by G. Lindstroem and M. Bruzzi

- Goal: Identify defects causing change of detector properties, namely trapping, leakage current and N_{eff} (V_{dep})

- Work: Defect Analysis on identical samples performed with the various tools available in the RD 50 Collaboration:
e.g. C-DLTS (Capacitance Deep Level Transient Spectroscopy), I-DLTS (Current Deep Level Transient Spectroscopy), TCT (Transient Charge Technique) or CV/IV, etc.



G. Casse, M.Moll, LHCC report 2012

I.Pintilie et al., Appl. Phys. Lett.92 024101,2008

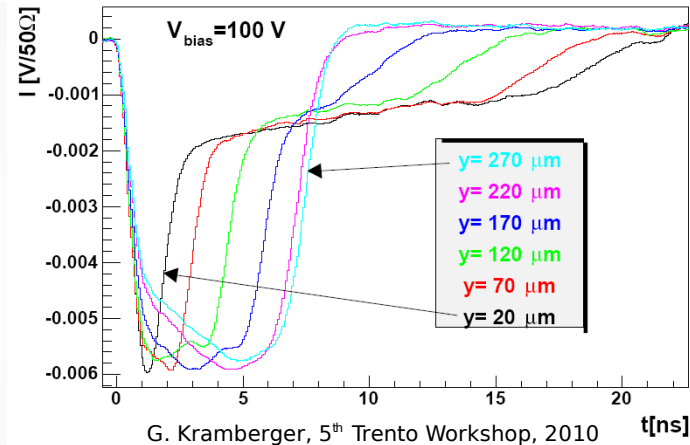
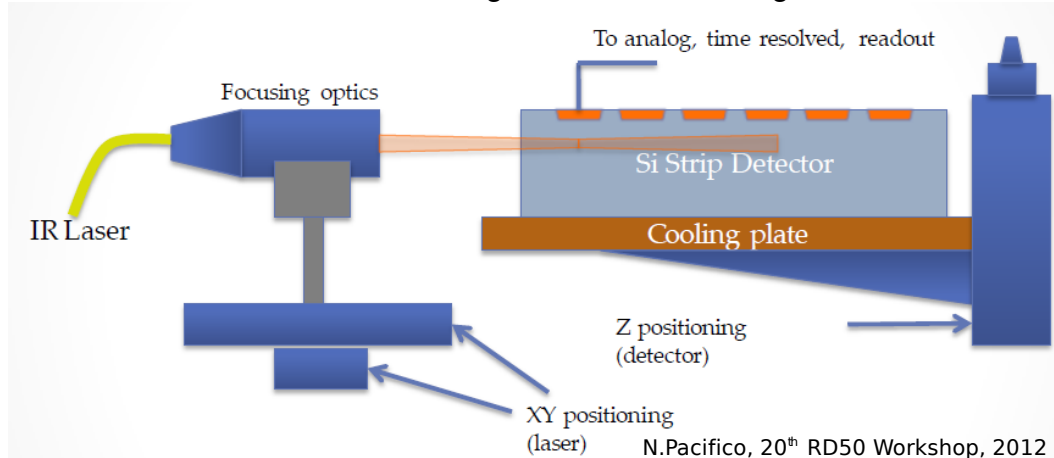
Detector Characterization: Investigation of Electric Fields with Edge-TCT

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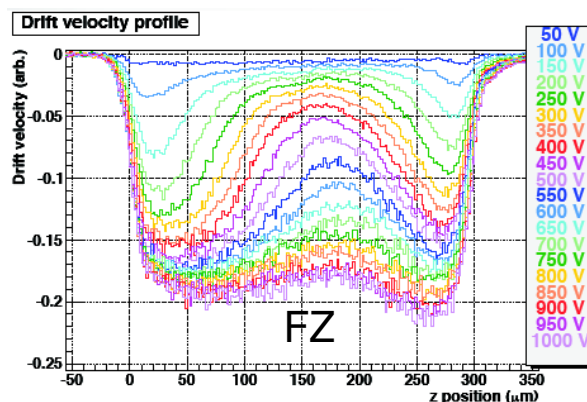
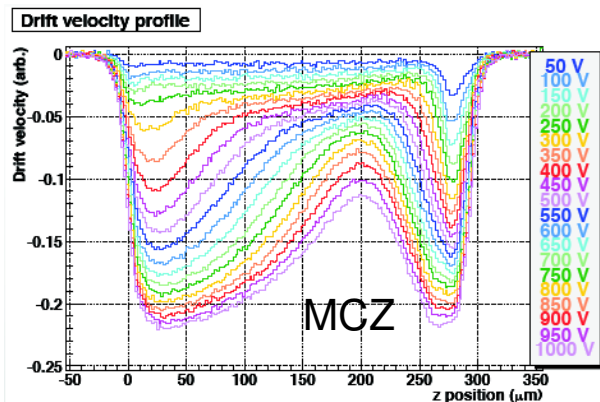
- Goal: Measurement of electric field in unirradiated and irradiated devices, usual TCT (Transient Charge Technique) not working due to trapping after irradiation

Edge-TCT, G. Kramberger, IEEE TNS, VOL. 57, NO. 4, AUGUST 2010, 2294



G. Kramberger, 5th Trento Workshop, 2010

- Example: n-on-p strip detector (pitch 80 μm), irradiated to $1 \cdot 10^{16}$ neq/cm², with protons, no annealing



$I(y, t \sim 0)$ proport. $v_e + v_h$
Different drift velocity in FZ and MCZ silicon

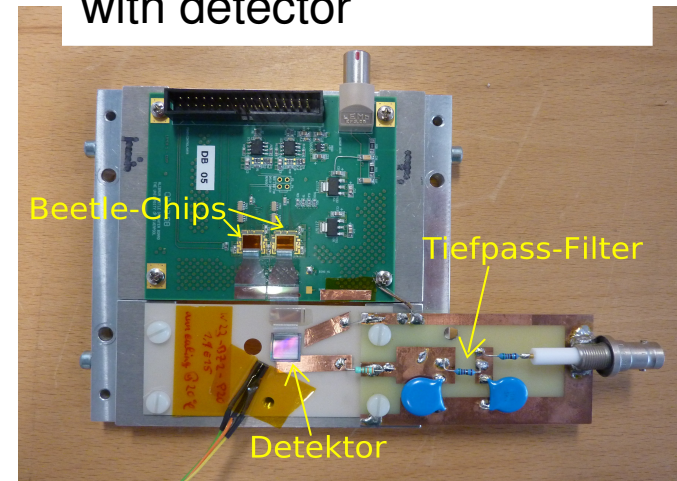
See also next talk N25-2

N.Pacifico, 20th RD50 Workshop, 2012

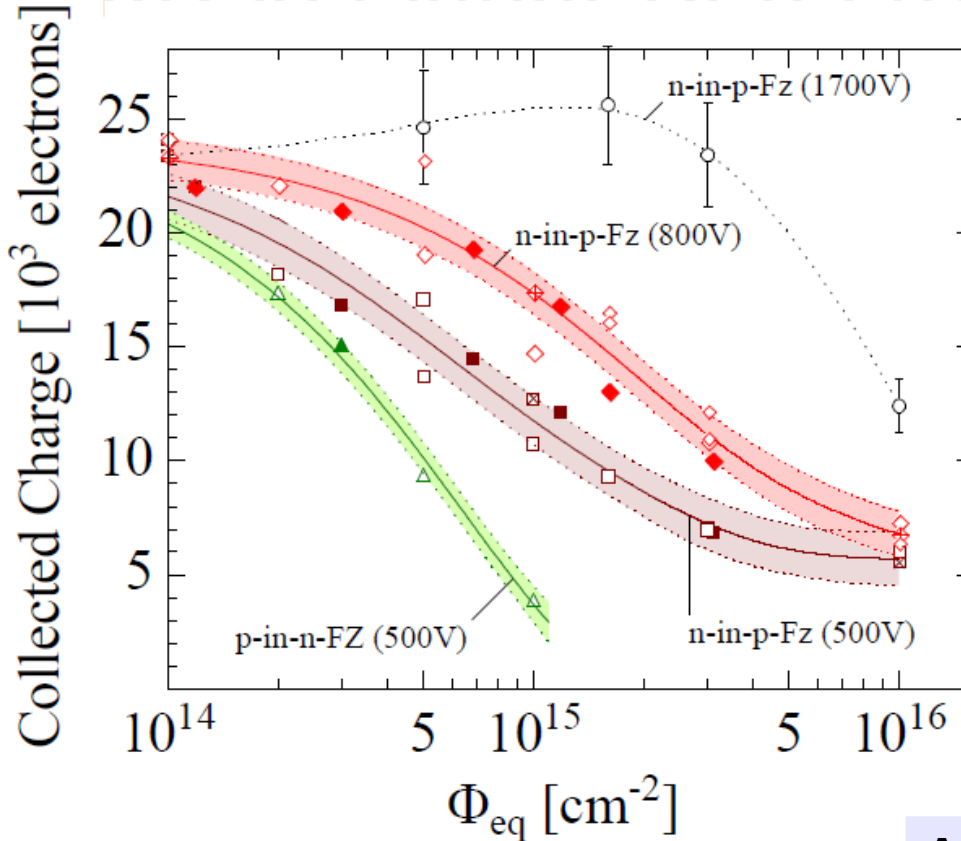
Systematic evaluation of strip and pixel sensors before and after irradiation with protons, neutrons, pions

- Use fast (40 MHz) analogue or binary readout electronics
- Determine parameters like collected charge, noise, signal-to-noise by using beta source set-ups, laser set-ups and testbeams
- Design and realization of pixel/strip detectors in contact with manufacturers (CiS, CNM, HIP, HPK, Micron, Sintef)

ALIBAVA daughter board with detector



- RD50 test beam setup (additional to other setups in the Collaboration (EUDET, CMS))
 - Based on ALIBAVA system with analogue fast readout
 - Device under test and sensors for track reconstruction run with same readout
 - Allows easy handling and high resolution measurements



FZ Silicon Strip Sensors

- n-in-p (FZ), 300μm, 500V, 23GeV p
- n-in-p (FZ), 300μm, 500V, neutrons
- ⊠ n-in-p (FZ), 300μm, 500V, 26MeV p
- ◆ n-in-p (FZ), 300μm, 800V, 23GeV p
- ◇ n-in-p (FZ), 300μm, 800V, neutrons
- ⊞ n-in-p (FZ), 300μm, 800V, 26MeV p
- n-in-p (FZ), 300μm, 1700V, neutrons
- ▲ p-in-n (FZ), 300μm, 500V, 23GeV p
- △ p-in-n (FZ), 300μm, 500V, neutrons

RD50 - M. Moll

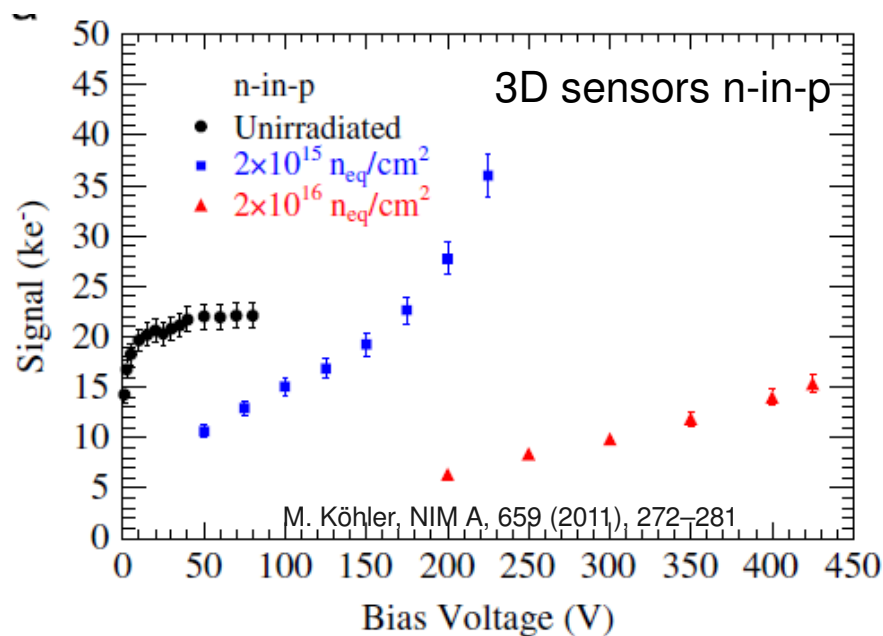
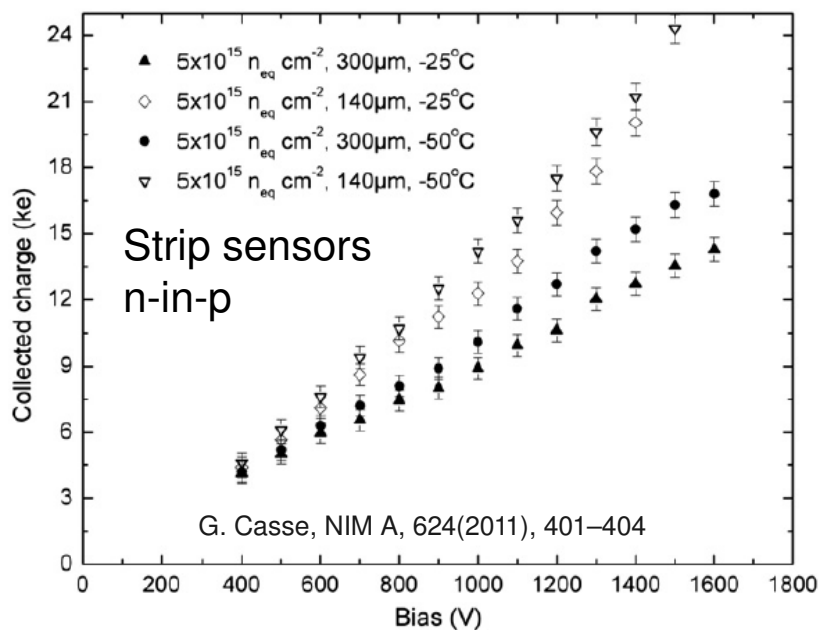
→ n-in-p performs best:
 No space charge inversion
 Collection of electrons (fast), shorter trapping times
 Charge multiplication at high bias voltages

Annealing:
 More investigations ongoing, aim for
 → proper description of scaling
 → recommendations for HEP community regarding temperature sensitive operation

Full detector systems: Charge Multiplication



More than 100% collected charge seen after irradiation to $2\text{-}5 \times 10^{15}$ neq/cm²: charge multiplication observed in pad, strip and 3D detectors



Charge Collection (Beta source, Alibava readout)

Goals: Understanding and Simulating charge multiplication

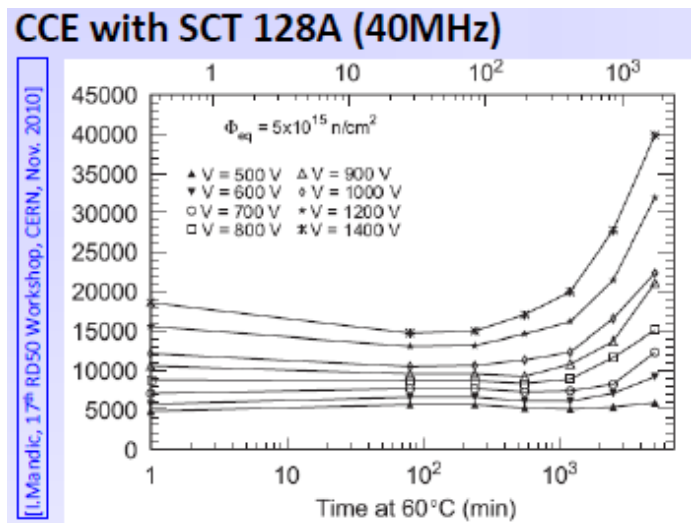
→ **Simulation Group** formed, lead by V. Eremin (Ioffe):

- Start from common parametrization
- Understand trapping, charge multiplication and avalanche effects
- Estimate electric fields and currents

Full detector systems: Charge Multiplication



CM observed after long annealing times



HPK FZ n-in-p strip sensors, thickness 320 μm

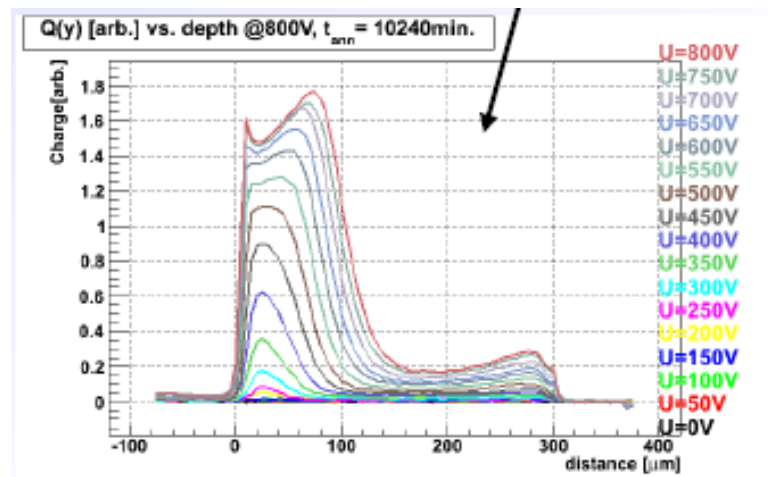
- Increase of the electric field close to the strips causing impact ionization/carrier injection when high concentrations of effective acceptors are introduced at very high fluences.

- **Open questions:** long-term stability, operation at high voltages, behaviour of signal-to-noise ratio

- **Problems:** high leakage currents, noise multiplication

Edge-TCT measurements indicate where charge is generated and multiplied

G. Casse M. Moll, LHCC Report, 2012
[M. Milovanović, 19th RD50 Workshop, Nov.2011]

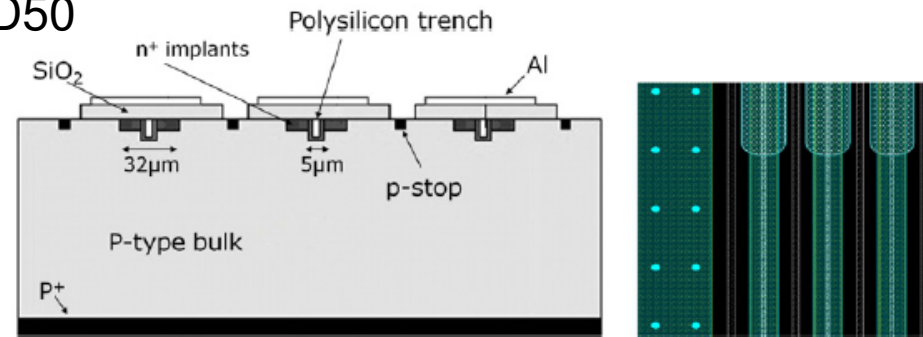


Full detector systems: Enhancing Charge Multiplication

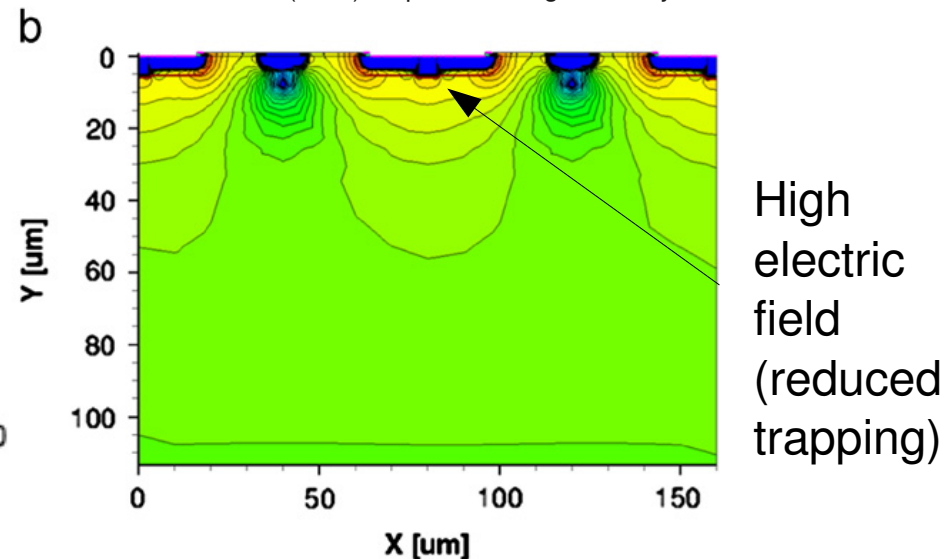
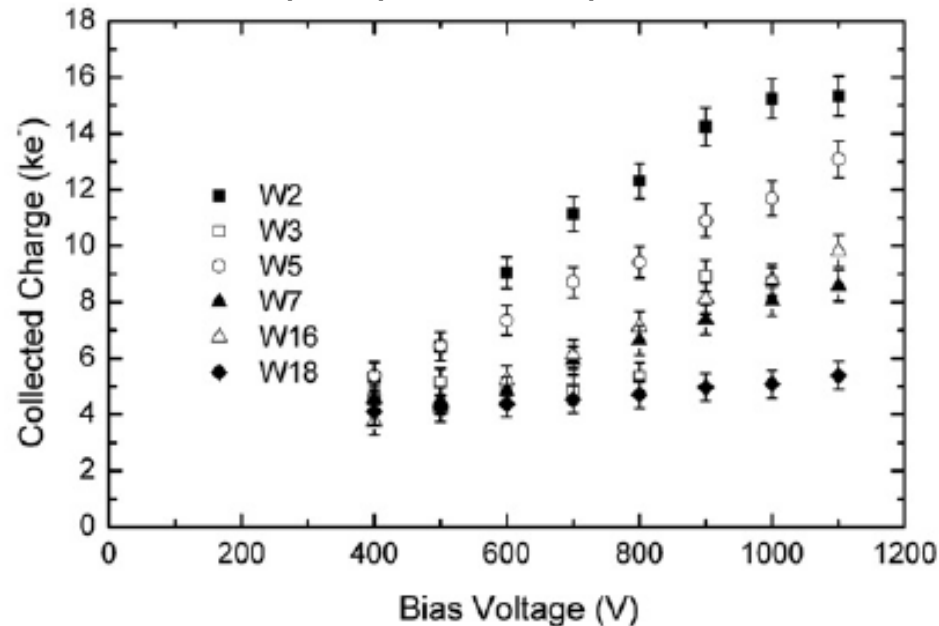
Production of sensors with trenches within RD50

Geometry variations:

- Deeper junctions
- Altered doping gradient
- Ratio of strip implant and pitch



G. Casse, NIM A (2012), <http://dx.doi.org/10.1016/j.nima.2012.04.033>



High electric field (reduced trapping)

P. Fernández-Martínez, NIM A 658 (2011) 98-102

→ Higher collected charge for 5 and 50 µm trenches but higher noise to be avoided

Standard n-in-p sensor 300 µm thick,
Trenches with 5 (W2), 10 (W7 std), 50 (W5) µm width, Deep diffusion 5 µm (W16), as implant (W18) after $5 \cdot 10^{15}$ neq/cm²

More in talk N25-3

New Structures: 3D sensors

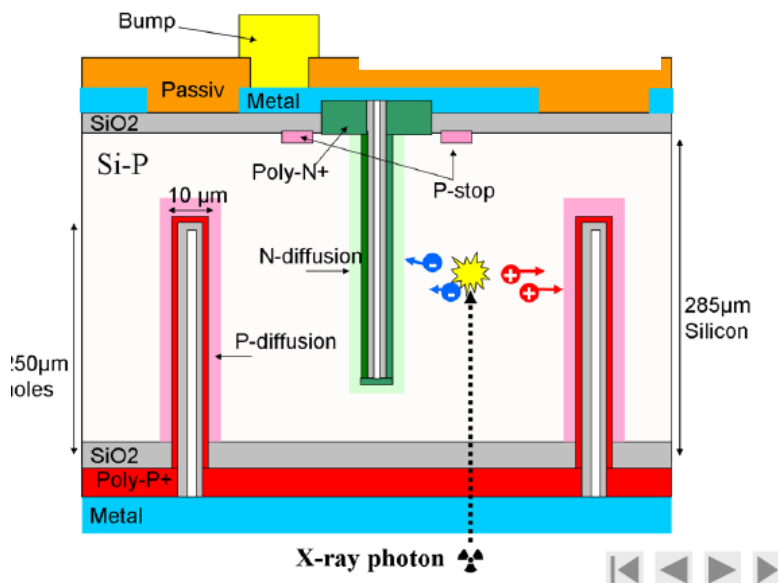
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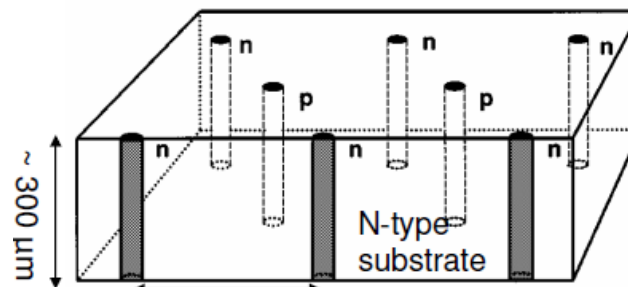
First proposed in 1997 by Parker et al.
 - Decoupling of depletion voltage and detector thickness (collected charge)

Today available in double-sided technology from different suppliers (CNM, FBK, Sintef)

- CNM: columns part. filled

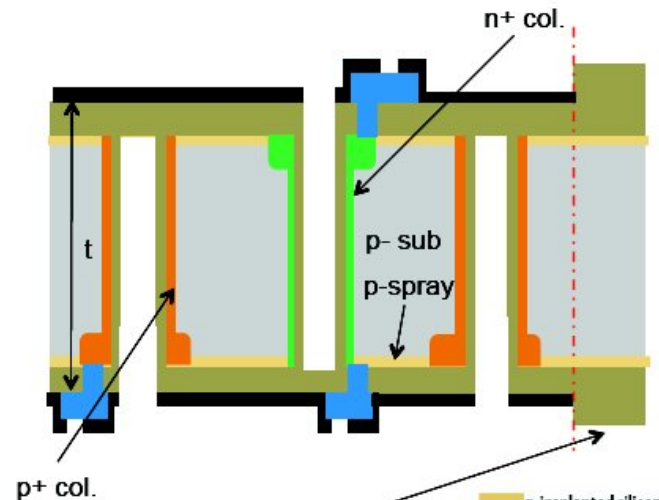
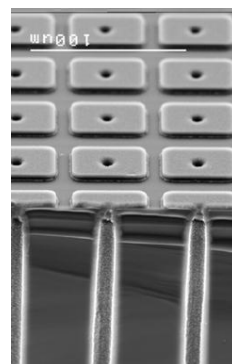


G. Pellegrini, NIM A 592 (2008) 38-43



50 µm - 100 µm Parker et al. NIM A 395 (1997) 328

- FBK 3D double side double type sensor: columns through wafer, empty



edge protection implemented with two different options

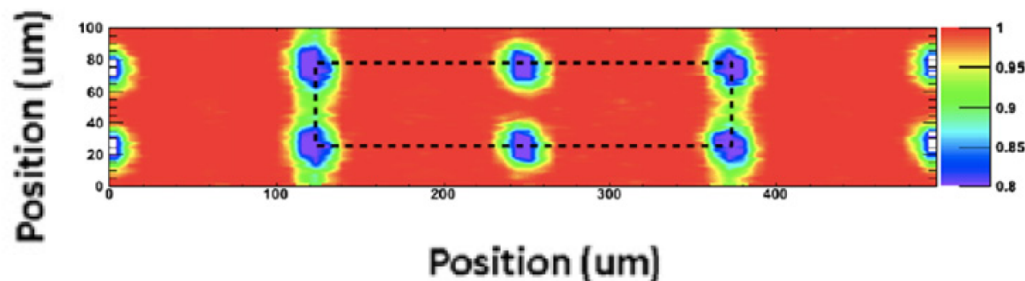
- p-implanted silicon
- n-diffused silicon
- p-diffused silicon
- Aluminum metal
- dielectric
- silicon
- PECVD overglass

E. Vianello, 16th Trento Workshop, 2011

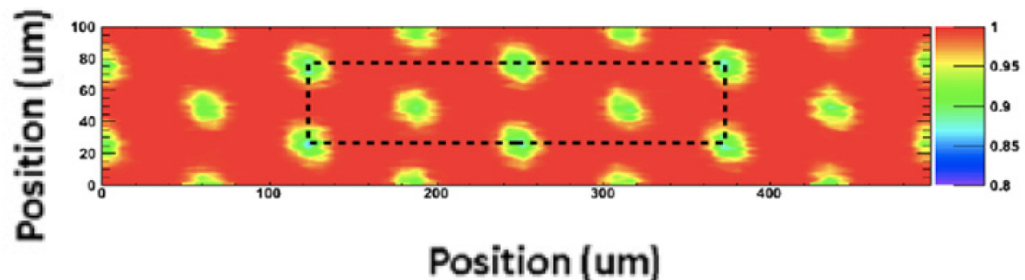
3D sensors of CNM and FBK show good performance before and after irradiation in charge collection measurements with beta sources and position resolved efficiency measurements with laser set-ups

Ex: Testbeam results of 3D pixel devices

S. Grinstein et al. NIM A (2012),
<http://dx.doi.org/10.1016/j.nima.2012.03.043>



Efficiency map for neutron irradiad.
 $5 \cdot 10^{15}$ neq/cm² CNM detector,
particles perpendicular, $V_{\text{bias}} = 160$ V
→ Overall eff. 97.5 %



Efficiency map for unirrad, FBK
detector, particles perpendicular,
 $V_{\text{bias}} = 20$ V
→ Overall eff. 98.8 %

→ ~ 20 % of sensors for ATLAS IBL will be 3D sensors

Summary: Achievements of RD 50 in light of LHC experiments

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- Observed radiation damage in LHC experiments agrees with predictions developed by RD 50
 - Leakage current increase in ATLAS, depletion voltage evolution in LHCb
- P-type silicon shows radiation hardness and good performance for fluences of about $1 \cdot 10^{16}$ neq/cm²
 - candidate material for upgrade of LHC strip tracking detectors
 - scaling of annealing to be investigated further
- New structures like 3D devices show good performance after irradiation and application in LHC experiments foreseen
- Charge multiplication investigation started systematically to allow its exploitation
 - long-term stability to be tested
- Radiation Damage Inter-Experiment Working Group
 - Common detector productions, test beams
 - “LHC-wide” exchange of knowledge

- RD 50 collaboration works on radiation hard semiconductor devices for LHC experiments and tested plenty of different devices (material, geometry, engineering)
- Several posters on topics of RD 50 collaboration:
 - N1-179, N1-181, N1-182
 - N14-57, N14-58, N14-198, N14-204, N14-206, N14-208, N14-215
- And many talks:
 - N18-7, N25-2, N25-3, N25-4
 - N33-1, N33-3, N33-5, NR01-2

Very active community and many projects ongoing!
Thank you to all colleagues for the material!

Backup

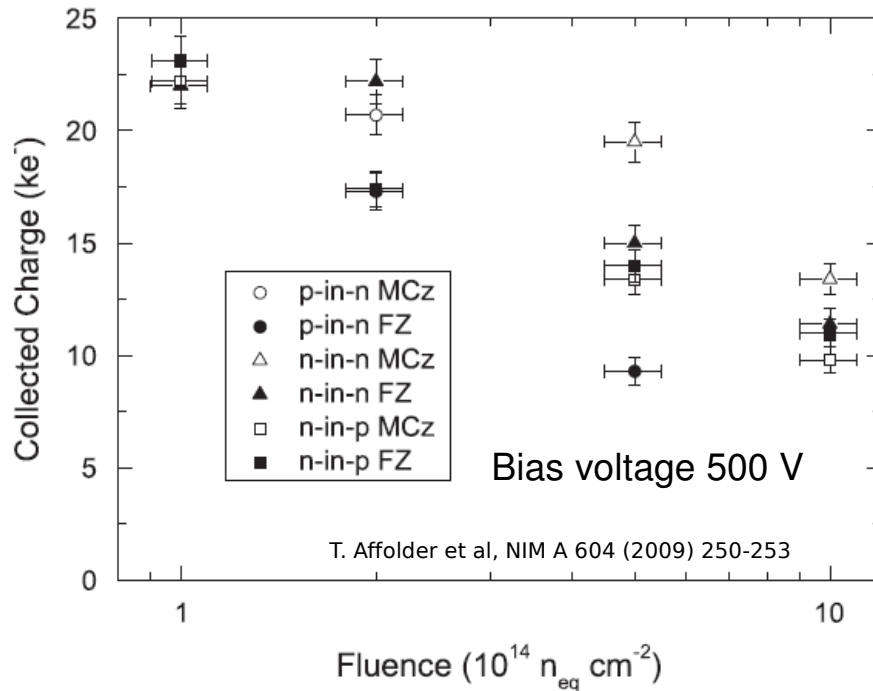
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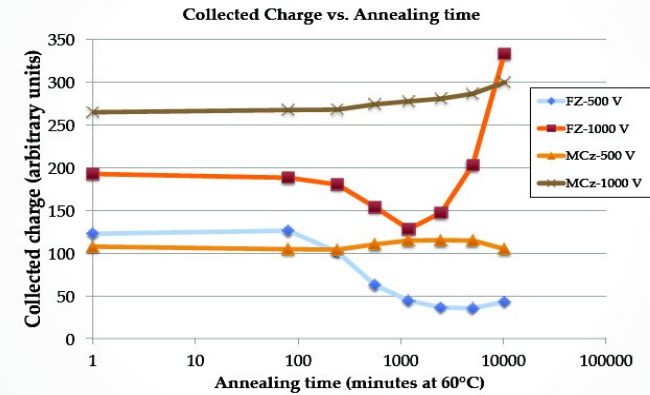
**UNI
FREIBURG**

Full detector systems: FZ vs. MCZ

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Collected charge - comparison



● N. Pacifico - 19th RD50 Workshop - CERN

22/11/2011 ● 21

N.Pacifico, 19th RD50 Workshop, 2011

Sensors 300 μm thick and neutron irradiated

- MCZ performs better than FZ
- MCZ less affected by annealing
In oxygen rich MCZ, damage compensated

Annealing:

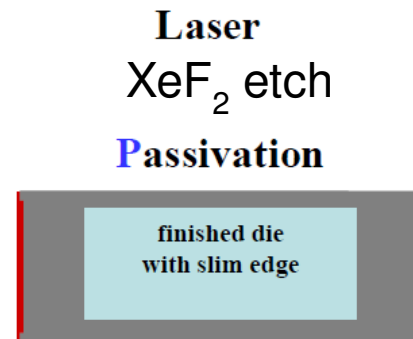
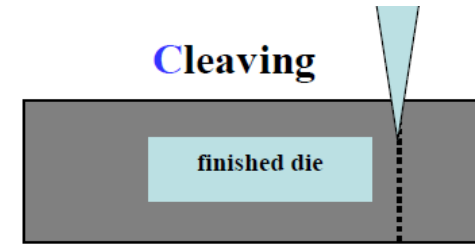
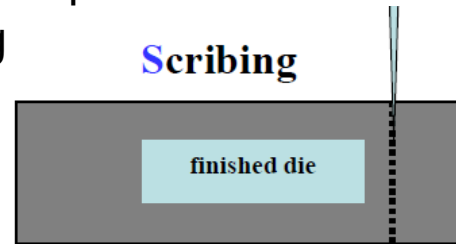
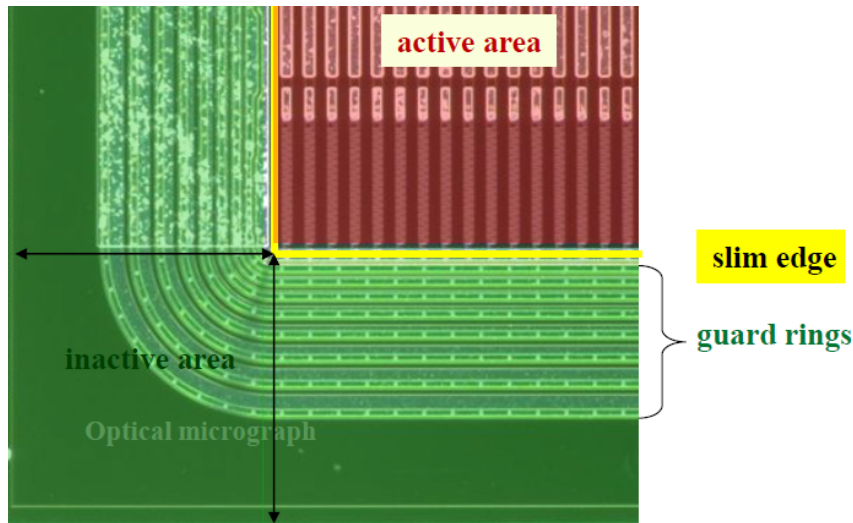
More investigations ongoing, aim for
→ proper description of scaling
→ recommendations for HEP community
regarding temperature sensitive operation

Further projects in RD 50

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- Investigation of thin sensors
 - 140 μm strip and 75 μm and 150 μm pixel devices tested, allow lower bias voltages
 - With charge multiplication thin sensors give large signals after high fluences
- RD 50 slim edge project to reduce dead space of inactive volume
 - Exploits scribe and cleave technique on planar and 3D devices
 - Performance after irradiation ongoing

More in talk N25-4



Tweezers

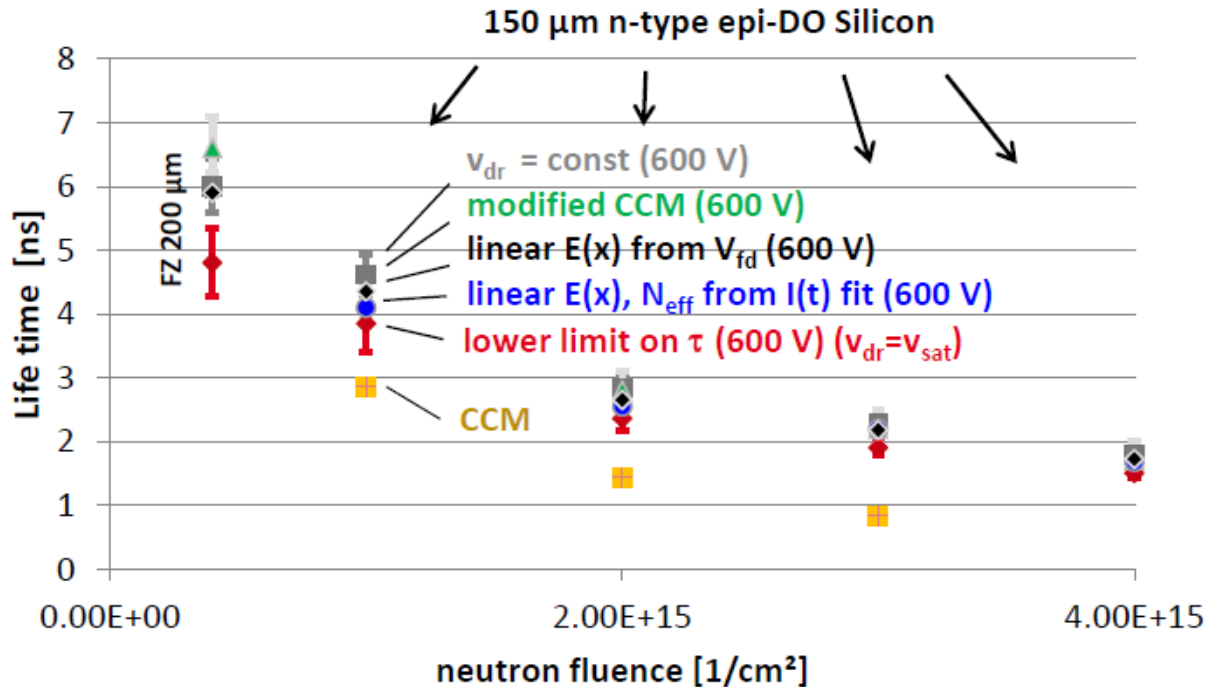
More in talk NR01-5

Native Oxide (n-type) + **Radiation** **Aluminum ALD** (p-type)

V. Fadeyev, 20th RD50 Workshop, 2012

TCT: Lifetime of charges

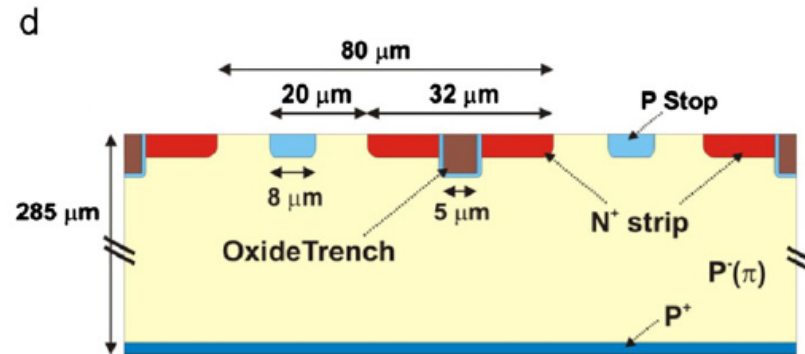
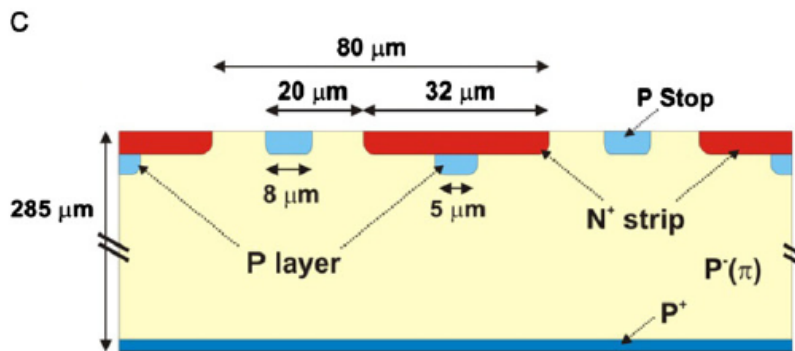
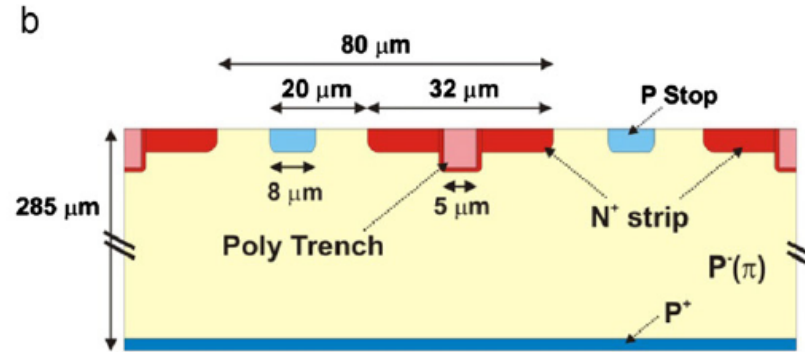
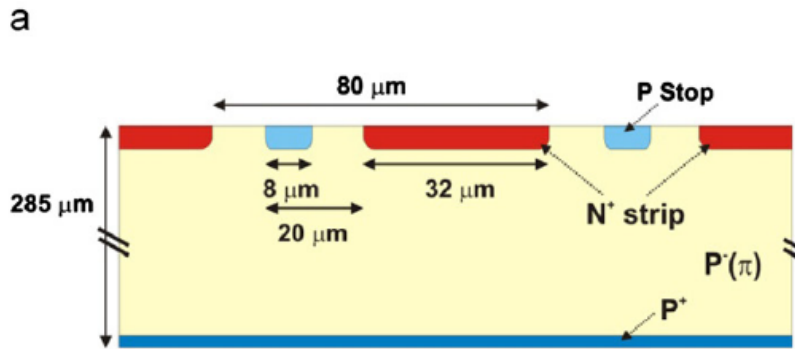
Estimate and Understand with TCT measurements the charge life time



- ◆ $v = v_{sat} = 1e7$ cm/s with syst. uncertainty (3% CCE)
- $v_{dr}=\text{const}$, cct \pm 0.1 ns
- ▲ modified CCM with syst. uncertainty (electronics)
- $E(x)$ linear, N_{eff} fitted
- Charge correction method (CCM)
- ◆ $E(x)$ linear, N_{eff} from V_{fd}

T. Pöhlsen, 20th RD50 Workshop, 2012

a standard, b poly trench including poly silicon doped with phosphorus, c p-layer with p-type diffusion, d oxide trench



P. Fernández-Martínez, NIM A 658 (2011) 98-102